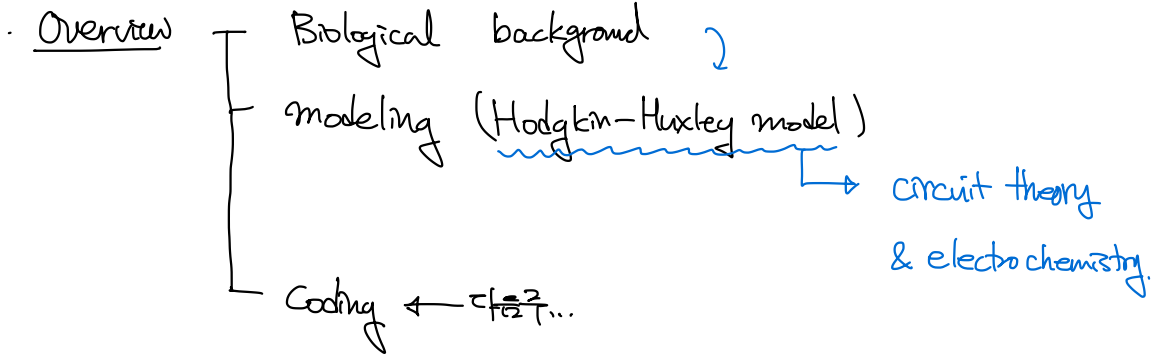


Week 6. Neuron & Hodgkin-Huxley model

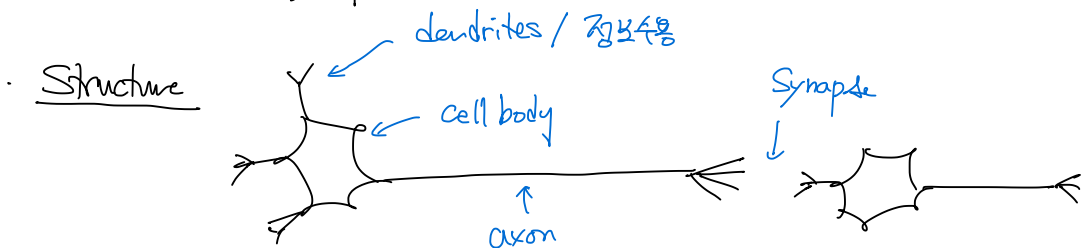


- motivation : Brain is complex system that consists of a lots of "Neurons"

Single Neuron → Neural Network → Brain (?)

· Biological background

- Neuron
1. Structure
 2. membrane potential (휴지막 전위)
 3. Action potential (활동전위)
 4. Synapse



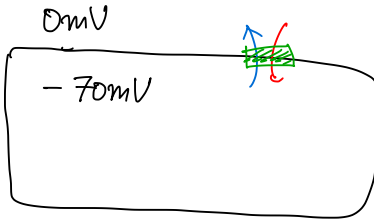
input →

neuron

→ output

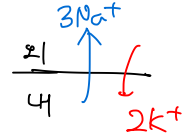
membrane potential / 평형전위 = -70 mV

$$\Delta V = V_{\text{내부}} - V_{\text{외부}}$$



※ $\text{Na}^+ - \text{K}^+ \rightarrow$ 세포 외부 $\text{Na}^+ \uparrow$
내부 $\text{K}^+ \uparrow$

표인 $\text{Na}^+ - \text{K}^+$ pump



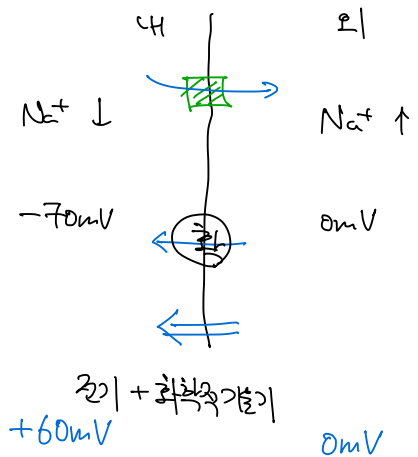
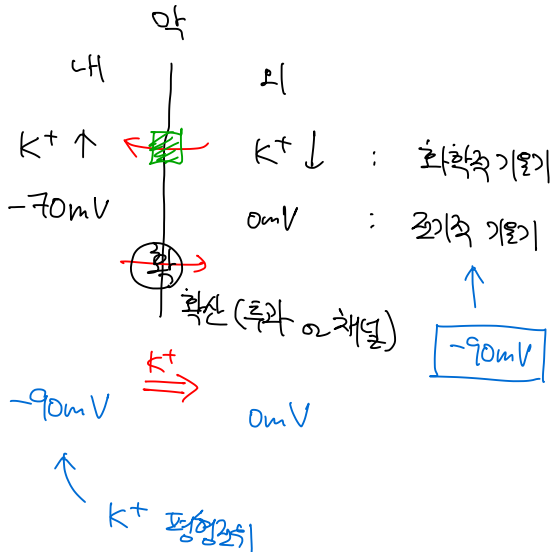
diffusion / 누과도 (leak) (채널 수)

$\text{Na}^+ : \text{K}^+$

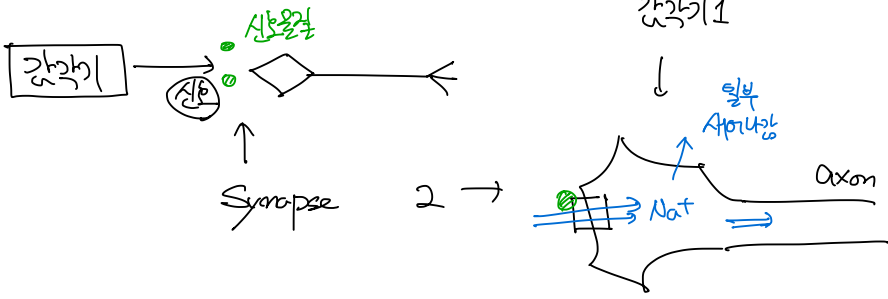
1 : 50

동위원종 같지만

세포 내부 음전하 단백질 ↑



Action potential



시간적 변화

전

+	(불극)
-	
Resting potential	
(-70mV)	

직후

-	(과분극)	+
+	Depolarized	-
+30mV		

Na⁺ ↑

Voltage gated Na⁺ channel (-55mV 열림)

후

과분극	과분극	불극

K⁺ ↓

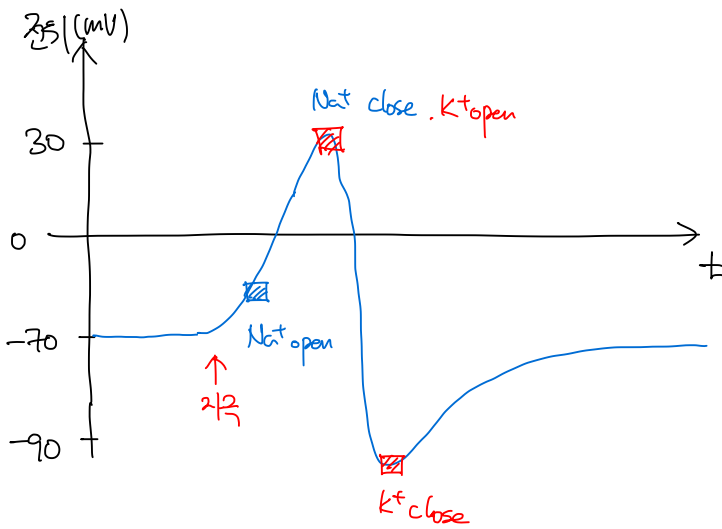
Voltage gated K⁺ channel (+30mV open)

더 후

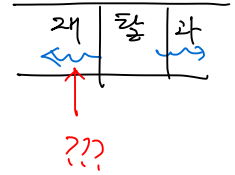
과분극 (hyperpol.)	과	탈	분
-90mV		+30mV	-70mV

더더 더 후

분	과	과	과	분
-70mV	-90mV		+30mV	-70mV

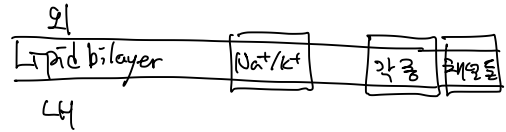


Question

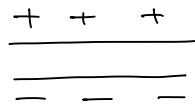


modeling (H-H model) ← How can we model action potential?

- membrane current
- Nernst equation
- Voltage gated & leak channel



membrane current



$$\sim \Delta V \frac{+Q}{-Q} \quad \text{Capacitor}$$

$$Q = C \Delta V \quad \frac{\Delta Q}{\Delta t}$$

$$\text{전하량 } Q \propto \Delta V$$

$$\Rightarrow I_{\text{mem}} = \frac{dQ}{dt} = C \frac{dV_{\text{mem}}}{dt}$$

$$\therefore Q = C \Delta V$$

· Nernst equation : electrochemical eqn.

$$nFE_{el} = nFE^{\circ} - RT \ln \frac{[Na^{+}]_{el}}{[Na^{+}]_{cy}}$$

(derivation) from $\Delta G = \Delta G^{\circ} - RT \ln Q$. & $\Delta G = W_{\text{elec}} = nFE$

$$\Rightarrow E_{el} - E_{cy} = \frac{RT}{nF} \ln \frac{[Na^{+}]_{cy}}{[Na^{+}]_{el}} = 0.0592 \log_{10} \frac{[Na^{+}]_{cy}}{[Na^{+}]_{el}} \equiv V_{\text{Nernst}}$$

· Voltage gated & leak channel

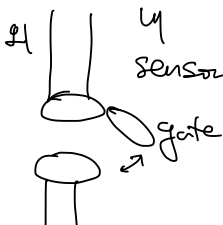
$$\text{from } \Delta V = IR, \quad I = \frac{\Delta V}{R} \stackrel{\text{let}}{=} g \cdot \Delta V$$

↖ conductance (전도도) describes

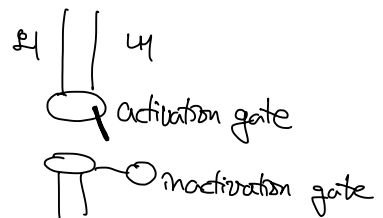
Voltage gated & leak channel

How? Two kinds of conductance (Voltage gated channel)

Persistent conductance
(지속성) (K^{+})



Transient conductance
(일시성) (Na^{+})



✓ K⁺ Conductance is constructed w/ four identical subunits.

$$P_k = n \cdot 4$$

↓

Prob. of channel opening

fraction of opened K⁺ indep. subunits.
also varies dep. on Voltage.

$$\frac{dn}{dt} = \underbrace{\alpha_n(V)}_{\substack{\uparrow \\ \text{rate constants to} \\ \text{open subunit}}} (1-n) - \underbrace{\beta_n(V)}_{\substack{\uparrow \\ \text{rate constants to} \\ \text{close subunit}}} \cdot n$$

rate constants to
open subunit

rate constants to
close subunit

$$\left(\times \frac{1}{\alpha_n(V) + \beta_n(V)} \right) \Rightarrow \tau_n(V) \frac{dn}{dt} = \underbrace{n_{\infty}(V)}_{\frac{\alpha_n}{\alpha_n + \beta_n}} - n$$

Thermodynamically,

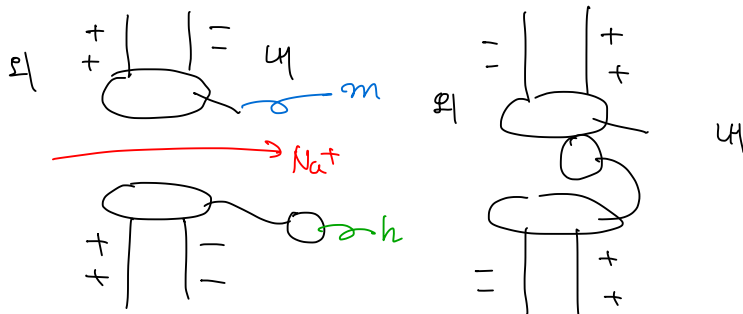
$$\alpha_n(V) \propto e^{(-aV/k_B T)}$$

Boltzmann factor

$$\beta_n(V) \propto e^{(-bV/k_B T)}$$

data fitting

✓ Na⁺ Conductance



$$P_{Na} = m^3 h$$

fraction of "non-activation gate" (opened)
 fraction of opened "activation gate" different voltage dep.

$$\frac{dm}{dt} = \alpha_m(V) (1-m) + \beta_m(V) m \quad (\text{or } h)$$

• Hodgkin-Huxley model

$$I_m = C_m \frac{dV_m}{dt} + \bar{g}_K n^4 (V - V_K) + \bar{g}_{Na} m^3 h (V - V_{Na}) + \bar{g}_L (V - V_L)$$

↑ Nernst
↑ Nernst
↑ Na⁺-K⁺ pump effect
↑ leak channel

